

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	62918	(chamber or vessel or enclosure or container or reactor) same plasma	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 20:56
L2	14615	1 and (workpiece or wafer or sample or film or semiconductor or substrate) and (ion near5 (energy or source or produc\$3 or generat\$3))	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 20:59
L3	8443	2 and (controller or microcontroller or microprocessor or processor or chip or (integrat\$3 near2 circuit))	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:00
L4	763	3 and ((differen\$3 or serveral or vary or varying or variable or varried) near4 frequenc\$2)	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:02
L5	310	4 and phenomen\$5	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:03
L6	60	4 and "315"/\$.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:03
L7	207	4 and "118"/\$.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:03
L8	51	4 and "250"/\$.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:04
L9	287	6 or 7 or 8	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:04
L10	476	4 not 9	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/12 21:04